

35.C10530C/D2

#2
Pre Amended
7.29.99
Ryf
PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
KIYOFUMI SAKAGUCHI ET AL.) Examiner: NYA
Divisional of)
Application No.: 08/863,717) Group Art Unit: NYA
Filed: Herewith)
For: PROCESS FOR PRODUCTION)
OF SEMICONDUCTOR)
SUBSTRATE) September 28, 1998

PRELIMINARY AMENDMENT

Assistant Commissioner for Patents
Washington, D.C. 20231

Sir:

Preliminary to the examination on the merits,
please amend the above-identified application as follows:

IN THE CLAIMS:

Please cancel claims 1-21 without prejudice or
disclaimer.

Please add the following new claims 22-96:

--22. A process for producing a semiconductor
substrate comprising the steps of: